



Docket No.: 543822005300  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Steven WANG et al.

Application No.: 10/812,412

Confirmation No.: 1275

Filed: March 30, 2004

Art Unit: 2814

For: METHOD FOR PRODUCING A DEEP  
TRENCH CAPACITOR IN A  
SEMICONDUCTOR SUBSTRATE

Examiner: N.W. Ha

**AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION**

MS Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

**INTRODUCTORY COMMENTS**

This is in response to the non-final Office Action dated January 6, 2006, for which a response was due on April 6, 2006. Accordingly, this response is timely filed. Reconsideration and allowance of the pending claims, as amended, in light of the remarks presented herein are respectfully requested.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 4 of this paper.